

+

SIGRAFINE® R6510

Ŧ

Material: Graphite

Forming: Isostatically pressed

Application: Semiconductor, photovoltaics

SIGRAFINE® is the new brand name for our fine-grain graphites, previously known under the names RINGSDORFF®, SIGRAFORM®, SIGRAMENT® and CRYSTA-SIL®.

Material data of SIGRAFINE® R6510

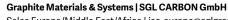
Typical properties	Units	Test standards	Values*
Average grain size	μm	ISO 13320	10
Bulk density	g/cm ³	DIN IEC 60413/204	1.83
Open porosity	Vol. %	DIN 66133	10
Medium pore entrance diameter	μm	DIN 66133	1.8
Coefficient of permeability (ambient temperature)	cm²/s	DIN 51935	0.06
Rockwell hardness HR _{5/100}		DIN IEC 60413/303	90
Resistivity	μΩm	DIN IEC 60413/402	13
Flexural strength	MPa	DIN IEC 60413/501	60
Compressive strength	MPa	DIN 51910	130
Dynamic modulus of elasticity	MPa	DIN 51915	11.5 x 10 ³
Thermal expansion (20 – 200 °C)	K ⁻¹	DIN 51909	4.2 x 10 ⁻⁶
Thermal conductivity (20 °C)	Wm ⁻¹ K ⁻¹	DIN 51908	105
Ash content	ppm	DIN 51903	**

^{*} Value might be changed due to material size

* registered trademarks of SGL CARBON SE

08 2015/0 1NÄ Printed in Germany

This information is based on our present state of knowledge and is intended to provide general notes on our products and their uses. It should therefore not be construed as guaranteeing specific properties of the products described or their suitability for a particular application. Any existing industrial property rights must be observed. The quality of our products is guaranteed under our "General Conditions of Sale".





Sales Europe/Middle East/Africa | iso-europe@sglgroup.com Sales Americas | iso-americas@sglgroup.com Sales Asia/Pacific | iso-asia@sglgroup.com www.fine-grain-graphite.com | www.sglgroup.com/gms

^{**} Ash value according to purity specifications